



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Toshiyuki OGATA, et al.

Application No. 09/922,723

Group Art Unit: 1752

Confirmation No.: 1261

Examiner: To be assigned

Filed: August 7, 2001

For: POSITIVE RESIST COMPOSITION AND BASE MATERIAL CARRYING LAYER OF
THE POSITIVE RESIST COMPOSITION

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INFORMATION DISCLOSURE STATEMENT
UNDER 37 C.F.R. §§ 1.97 and 1.98

Commissioner for Patents
Washington, D.C. 20231

Sir:

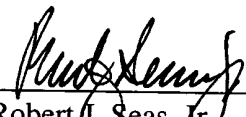
Pursuant to Applicants' duty of voluntary disclosure under Rule 56, and for the
Examiner's convenience, we submit herewith:

- a) a form PTO-1449 listing three (3) references of potential relevancy; and,
- b) a complete copy of each reference.

No certification or fee is required.

Regarding the concise explanation of relevancy requirement for foreign language
documents, an English language abstract is enclosed for each reference.

Respectfully submitted,


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Date: October 16, 2001